

Consul General's Visit to Suzhou Industrial Park

On 22 January, Mr. Anil Rai, Consul General of India in Shanghai led a delegation including Ms Sumita Dawra, Joint Secretary (Industries) DPIIT and Mr. Raja Khurana, from Invest India to visit Suzhou Industrial Park, to exchange ideas and seek investment opportunities between both sides.



Suzhou Industrial Park(SIP) was established in February 1994 and was the first government cooperation project between China and Singapore. SIP is regarded as a successful model of international cooperation. It is also the first open innovation comprehensive experimental area of China. It covers an administrative area of 278 sqkm.

Ms Liu Hua, Vice Chairman of SIP Administrative Committee, together with Ms Zhong Maohua, Deputy Director of SIP FAO; Ms Sheng Ji, Deputy Section Chief of SIP FAO; Mr Zhang Feng, Deputy Director of SIP Investment Promotion Board and Mr Wang Liying, officer of SIP Investment Promotion Board welcomed the delegation to Suzhou Industrial Park.



During the meeting, Ms Liu Hua first gave a brief introduction of the Suzhou Industrial Park, followed by Mr Zhang Feng who gave a detailed presentation of the background, achievements and future plans of SIP. After that, Mr. Raja Khurana gave a detailed presentation on investment scenario in India.



Both sides had a fruitful discussion over several issues such as organizing field visits to economic zones in India, cooperation in vocational training & skilling graduates; cultural workshops & representing India in business seminars organized by SIP.



In the afternoon, the delegation visited SIP Demonstration Center followed by a visit to BioBay in SIP, which plays a pivotal role in life science innovation, with a cluster of more than 400 high-tech start-ups in the fields of drug discovery, medical devices and diagnosis, biotechnology, nanotechnology and contract researches(CRO).


